

Amendments to the Claims

Please cancel claim 33.

Please amend claims 18, 34 and 35, as follows. The amendment to claim 18 corrects a typographical error. Support for the amendment can be found at column 8, lines 33-34. Support for the amendments to claims 34 and 35 can be found in original claim 33-35. In the following amendment to claim 18, Applicants have used double brackets to indicate material to be deleted, as the deleted text itself contains brackets.

18. (amended) The composite of claim 16 wherein the base is [[1,8diazobicyclo[5,4,0]undec-7-ene]] 1,8-diazobicyclo[5.4.0]undec-7-ene.

34. (amended) The composite of claim [33] 1 wherein the pendant phenolic group is an unsubstituted phenolic group.

35. (amended) The composite of claim [33] 1 wherein the pendant phenolic group is a substituted phenolic group.

Please add the following new claims:

49. A composition comprising:
a zinc chloride resistant polyamide having at least one pendant phenolic group; and a
base.

50. The composition of claim 49, wherein the polyamide is nylon-11 or nylon-12.

51. The composition of claim 49, wherein the polyamide further comprises at least one
pendant primary or secondary amine group.

52. The composition of claim 49, wherein at least one pendant phenolic group is an
unsubstituted phenolic group.

53. The composition of claim 49, wherein at least one pendant phenolic group is a substituted phenolic group.

54. The composition of claim 49, wherein the base is selected from the group consisting of amine compounds, hydroxide compounds, alkoxide compounds, and combinations thereof.

55. The composition of claim 49, wherein the base further comprises an organo-onium compound.

56. The composition of claim 49, wherein the base is 1,8-diazobicyclo[5.4.0]undec-7-ene.

57. The composition of claim 49, wherein the polyamide further comprises a polyether.

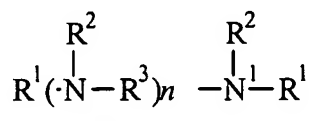
58. The composition of claim 49, wherein the at least one pendant phenolic group is a phenoxide.

59. The composition of claim 49, wherein the base is an organic base.

60. The composition of claim 59, wherein the organic base is selected from the group consisting of tertiary amines, amidines, alkoxide salts, sodium stearate, magnesium oxalate, benzotriazoate, and combinations thereof.

61. The composition of claim 59, wherein the organic base is an amine compound selected from the group consisting of aliphatic amines, aryl amines, amidine amines, and combinations thereof.

62. The composition of claim 59, wherein the organic base is an amine compound represented by the formula



where:

R¹, R² are independently selected from hydrogen, substituted and unsubstituted alkyl, cycloalkyl, aryl, aralkyl, and alkaryl groups, and

R³ is selected from substituted or unsubstituted alkylene, cycloalkylene, arylene, aralkylene, and alkarylene groups; n is a number from 0 to about 100.

63. The composition of claim 62, wherein each R¹ and R² is independently selected from the group consisting of substituted and unsubstituted alkyl, cycloalkyl, aryl, aralkyl, and alkaryl groups.

64. The composition of claim 49, wherein the base is an inorganic base selected from the group consisting of oxides, hydroxides, carbonates, and combinations thereof.

65. A composition comprising the reaction product of a zinc chloride resistant polyamide, a phenolic group, and a base.


66. A composition comprising the reaction product of a zinc chloride resistant polyamide and a reaction product of a phenolic group and a base.

67. The composition of claim 66, wherein the reaction product of the phenolic group and the base comprises a phenolic resin salt of 1,8-diazobicyclo[5.4.0]undec-7-ene.

Respectfully submitted,

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